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PATENT MAIL STOP AF

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Atty Docket No.

A01505

Appl No.:

10/811,009

Art Unit: 1711

Applicant:

Gene Kelly Norris et al.

Filed: March 26, 2004

Examiner: Patricia Hampton Hightower

Title: High-Melting Wax Useful for Sintering Metals

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In re application of: Gene Kelly Norris et al.

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RESPONSE UNDER 37 C.F.R. § 1.116

Mail Stop AF Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In response to the final Office Action mailed July 15, 2005, Applicants submit the following arguments.

The sections of this Response are organized as follows:

REMARKS AND ARGUMENTS begin on page 2 of this paper.